Anisotropic magnetization relaxation in ferromagnetic multilayers with variable interlayer exchange coupling

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The ferromagnetic resonance (FMR) linewidth and its anisotropy in $F_1/f/F_2/AF$ multilayers, where spacer f has a low Curie point compared to the strongly ferromagnetic F_1 and F_2 , is investigated. The role of the interlayer exchange coupling in magnetization relaxation is determined experimentally by varying the thickness of the spacer. It is shown that stronger interlayer coupling via thinner spacers enhances the microwave energy exchange between the outer ferromagnetic layers, with the magnetization of F_2 exchange dragged by the resonance precession in F_1 . A weaker mirror effect is also observed: the magnetization of F_1 can be exchange dragged by the precession in F_2 , which leads to antidamping and narrower FMR linewidths. A theory is developed to model the measured data, which allows separating various contributions to the magnetic relaxation in the system. Key physical parameters, such as the interlayer coupling constant, in-plane anisotropy of the FMR linewidth, and dispersion of the magnetic anisotropy fields, are quantified. These results should be useful for designing high-speed magnetic nanodevices based on thermally assisted switching.

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I. INTRODUCTION

Recently, there has been growing research interest in advanced magnetic multilayers due to their high potential for applications in magnetic random access memory and microwave devices [1–3]. Further technological progress requires a better understanding of the processes behind magnetic relaxation. Special attention should be paid to spin relaxation found in specific functional nanostructures not observed in bulk materials.

In bulk ferromagnets, the motion of the magnetization and its damping are well described by the Landau-Lifshitz-Gilbert equation [4–6]. The strength of the damping term is scaled by the Gilbert damping constant G, which is a key parameter for spin electronics since it determines the magnetization switching time and the critical current density in spin-torquebased devices [7–10].

The Gilbert damping parameter characterizes the energy transfer from the spin subsystem to the lattice [6]. Several microscopic mechanisms intrinsic to ferromagnetic materials, such as phonon drag [10] and spin-orbit coupling [11], have been proposed to account for magnetic relaxation represented by the Gilbert term. There are, however, two new mechanisms which have been the topic of recent discussion regarding magnetization damping in ultrathin films and multi-layers: two-magnon scattering [12,13] and the spin-pumping effect [14,15].

Two-magnon scattering is a process in which the magnon of the zero wave vector (k = 0) scatters into degenerate states of magnons with wave vectors $k \neq 0$ [12]. This process requires that the spin-wave dispersion contains degenerate states and that there are scattering centers in the sample. The geometrical separation of the scattering centers determines the spatial extent of the final magnon states. If long-wavelength spin waves are involved in the relaxation process, defects of the order of several hundreds of nanometers rather than atomic defects act as scattering centers. The existence of two-magnon scattering has been demonstrated in many systems of ferrites [16–18]. While in bulk materials this mechanism is well known, it was only recently found to be of importance also for multilayers [19,20] and ultrathin ferromagnetic films [21–23].

In the presence of an interface between a ferromagnetic and a nonmagnetic layer, the spin-pumping effect can cause an increase in the damping constant [14,15]. Excitation of a ferromagnet by a microwave field normally leads to a coherent precession of its spins, which can act as a spin battery injecting through the interlayer interface a pure spin current into the neighboring nonmagnetic layer. Due to the presence of impurity scattering in the system, this spin current can return to the interface, bringing the carried angular momentum back to the precessing spins of the ferromagnetic layer [24]. Depending on the parameters of the neighboring layers and interlayer interfaces, a portion of the angular momentum flow will be absorbed by the ferromagnetic layer via various spin-flip relaxation processes. Therefore, the backflow through the nonmagnetic/ferromagnetic interface is always weaker than the direct flow. This imbalance enhances damping of the magnetization precession [9,15,25].

The above spin-relaxation effects, being of wide fundamental and applied interest, can be studied most suitably using ferromagnetic resonance (FMR). This powerful method for characterizing magnetic materials relates the measured FMR linewidth to the spin-relaxation mechanisms outlined above. For Gilbert-type relaxation, the FMR linewidth (half width at half maximum) is $\Delta^{hwhm} = \alpha \omega/\gamma$, where α is a dimensionless damping parameter related to *G* as $\alpha = G/(\gamma M)$, ω is the angular frequency of the exciting field, γ is the modulus of the gyromagnetic ratio, and *M* is the ferromagnet's magnetization. Damping mechanisms extrinsic to the ferromagnet, such as spin pumping, result in additional contributions to the measured FMR linewidth and can be deduced by studying effects on the FMR from varying the physical parameters of the multilayer.

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We have recently developed magnetic multilayers with temperature-controlled interlayer-exchange coupling, the so-called *Curie-switch* or *Curie-valve* structures [26–28]. A Curie switch is a $F_1/f/F_2/AF$ multilayer where weakly ferromagnetic spacer f is sandwiched between soft ferromagnetic layer F_1 and hard ferromagnetic layer F_2 exchange pinned by antiferromagnetic layer AF. Magnetic coupling between F_1 and F_2 depends on whether temperature *T* is higher or lower than the Curie temperature of the spacer [29,30]. As a result, the switching of the magnetic configuration from parallel to antiparallel may be achieved by driving the spacer thermally through its Curie point [3,30].

Magnetic relaxation in a Curie switch has not been fully explored. This work is a study of the FMR properties of $F_1/f/F_2/AF$ multilayers, aimed at understanding the mechanisms involved and, specifically, the role the interlayer exchange coupling plays in spin relaxation in the system.

II. EXPERIMENTAL DETAILS

The experiments were carried out on multilayers $Py(10)/Ni_{54}Cu_{46}(d)/Co_{90}Fe_{10}(5)/Mn_{80}Ir_{20}(12)$ [hereinafter $F_1/Ni_{54}Cu_{46}(d)/F_2$] with spacer thicknesses d = 3, 4.5, 6, and 9 nm. The numbers in parentheses represent layer thicknesses in nanometers. The multilayers were deposited at room temperature on thermally oxidized silicon substrates using magnetron sputtering in an AJA Orion 8-target system. The exchange pinning between the ferromagnetic $Co_{90}Fe_{10}$ and antiferromagnetic $Mn_{80}Ir_{20}$ layers was set during deposition using an in-plane magnetic field $H_{dep} \approx 0.6$ kOe. Additional fabrication details can be found in Refs. [30,31].

Magnetic properties of the multilayers with a specific spacer composition (Ni₅₄Cu₄₆) were reported previously [3,30,31]. It was shown that at room temperature, the coupling between the F_1 and F_2 layers strongly depends on the spacer thickness *d*. The increase in *d* from 3 to 9 nm makes the system transition from a strongly coupled to a fully exchange decoupled regime.

FMR measurements were carried out using an X-band ELEXSYS E500 spectrometer equipped with an automatic goniometer. The operating frequency was $\nu = 9.44$ GHz. The out-of-plane and in-plane angular dependences of the FMR spectra were studied at room temperature (295 K). The resonance signals from both F₁ and F₂ were clearly separated in field.

The FMR measurements recorded the first derivative of the microwave absorption by the sample. Each spectrum was fitted by a field derivative of a Lorentzian function to obtain the relevant resonance field H_{ri} and linewidth $\Delta_i = 2\Delta_i^{hwhm}$ (i = 1, 2 correspond to layers F₁, F₂).

III. THEORETICAL DESCRIPTION

A. Effect of interlayer coupling

Consider a $F_1/f/F_2/AF$ multilayer where weakly ferromagnetic spacer f is sandwiched between soft magnetic F_1 and hard magnetic F_2 exchange pinned by AF [3,31]. The thicknesses of F_1 , F_2 , and f are, respectively, L_1 , L_2 , and d.

The calculation of the FMR modes will assume that the action of the applied uniform external field does not affect the uniform distribution of the magnetization M_1 and M_2 in F_1 and F_2 , respectively. In our case with thin layers and

strong intralayer exchange interactions, this assumption is well justified [3,32]. Spacer f with magnetization **m** provides a relatively weak coupling between the outer ferromagnetic layers. The aim of this section is to determine the effect of this coupling on the FMR linewidth Δ_1 .

For a uniform ferromagnetic layer, the energy density consists of magnetodipole and Zeeman terms. The exchange bias between F_2 and AF can be modeled using an effective biasing field H_b acting on the magnetization M_2 [3,33]. Using these notations, the expression for the energy density w_i of the *i*th layer can be written as a sum of the demagnetization term and the terms describing the interaction of the layers' magnetizations with the effective biasing (H_b), external quasistatic (H), and alternating (h) magnetic fields:

$$w_i = 2\pi M_i^2 \cos^2 \theta_i - M_i H_{bi} \cos \varphi_i \sin \theta_i - M_i H \cos(\varphi_i - \varphi_H) \sin \theta_i - M_i h \cos \theta_i, \quad (1)$$

where i = 1,2; M_i is the saturation magnetization of the *i*th layer; $H_{b1} = 0$, $H_{b2} = H_b$; *H* is the external quasistatic magnetic field applied in the film plane x Oy; *h* is the weak alternating magnetic field applied perpendicular to the film plane; φ_H is the angle between **H** and the Ox axis directed along **H**_b; and θ_i and φ_i are, respectively, the polar and azimuthal coordinates of the magnetization vector in the *i*th layer.

In the case of a thin film, its high out-of-plane demagnetization fields prevent the magnetization vector from strongly deviating from the x Oy plane. In this case, θ_i can be represented as $\theta_i = \pi/2 + \varepsilon_i$, where $|\varepsilon_i| \ll 1$. This makes it possible to simplify further calculations by expanding the energy density in powers of ε_i and keeping only terms not higher than quadratic in ε_i .

The equations of the magnetization dynamics, which take into account the weak coupling between F_1 and F_2 , can be obtained following the procedure described in Ref. [3]. Let us introduce Lagrange function L, averaged over two ferromagnetic layers, and dissipative function \Re in the Gilbert form:

$$L = T - W - \frac{4\pi\Lambda^2 m^2}{2d(L_1 + L_2)} [(\varphi_1 - \varphi_2)^2 + (\varepsilon_1 - \varepsilon_2)^2], \quad (2)$$

$$T = \sum_{i=1}^{2} -\frac{l_i M_i}{\gamma} \cos \theta_i \dot{\varphi_i} \approx \sum_{i=1}^{2} \frac{l_i M_i}{\gamma} \varepsilon_i \dot{\varphi_i}, \qquad (3)$$

$$W = \sum_{i=1}^{2} l_i w_i \approx \sum_{i=1}^{2} l_i \left[2\pi M_i^2 \varepsilon_i^2 - H_{bi} M_i \cos \varphi_i \left(1 - \frac{\varepsilon_i^2}{2} \right) - H M_i \left(1 - \frac{\varepsilon_i^2}{2} \right) \cos(\varphi_i - \varphi_H) \right], \tag{4}$$

$$\Re = \sum_{i=1}^{2} \frac{\alpha_i M_i l_i}{2\gamma} \left(\dot{\theta}_i^2 + \sin^2 \theta_i \dot{\varphi}_i^2 \right)$$
$$\approx \sum_{i=1}^{2} \frac{\alpha_i M_i l_i}{2\gamma} \left(\dot{\varepsilon}_i^2 + \dot{\varphi}_i^2 \right). \tag{5}$$

Here the dot over the angle variables θ_i , φ_i , and ε_i means differentiation in time. *T* and *W* are the kinetic and potential energies of the system, respectively, $l_i = L_i/(L_1 + L_2)$ is the

relative thickness of the *i*th ferromagnetic layer, α_i is the dissipative constant in the Gilbert form, and Λ is the magnetic exchange length of the material of the spacer, which is related to the spacer exchange constant ζ as $\Lambda = \sqrt{\zeta/4\pi}$ [3,34].

The last term in Eq. (2) describes the coupling energy between F_1 and F_2 . Its derivation and the limits of validity are detailed in Ref. [3].

The equations for the magnetization dynamics in the Lagrange form are [4]

$$\frac{d}{dt}\frac{\partial L}{\partial \dot{\varepsilon}_i} = \frac{\partial L}{\partial \varepsilon_i} - \frac{\partial \mathfrak{R}}{\partial \dot{\varepsilon}_i}, \qquad \frac{d}{dt}\frac{\partial L}{\partial \dot{\varphi}_i} = \frac{\partial L}{\partial \varphi_i} - \frac{\partial \mathfrak{R}}{\partial \dot{\varphi}_i}.$$
 (6)

After substitutions of Eqs. (1)–(5) into Eq. (6), we obtain

$$\frac{1}{\gamma}\frac{d\varepsilon_i}{dt} + \frac{\alpha_i}{\gamma}\frac{d\varphi_i}{dt} + H\sin(\varphi_i - \varphi_H) + H_{bi}\sin\varphi_i - k_i(-1)^i(\varphi_1 - \varphi_2) = 0, \qquad (7)$$

$$-\frac{1}{\gamma}\frac{d\varphi_i}{dt} + \frac{\alpha_i}{\gamma}\frac{d\varepsilon_i}{dt} + [4\pi M_i + H\cos(\varphi_i - \varphi_H) + H_{bi}\cos\varphi_i]\varepsilon_i - k_i(-1)^i(\varepsilon_1 - \varepsilon_2) = -h,$$
(8)

where $k_i = 4\pi \Lambda^2 m^2 / dL_i M_i$ is the effective coupling constant with the dimension of magnetic field, characterizing the exchange from the neighboring layers on the *i*th layer [3].

When the alternating magnetic field equals zero (h = 0), $\varepsilon_i = 0$, and the equilibrium angles φ_{0i} can be determined from the following equations:

$$H\sin(\varphi_{01} - \varphi_H) + k_1(\varphi_{01} - \varphi_{02}) = 0, \qquad (9)$$

$$H\sin(\varphi_{02} - \varphi_H) + H_{\rm b}\sin\varphi_{02} - k_2(\varphi_{01} - \varphi_{02}) = 0. \quad (10)$$

From our earlier work [3,31], $H_b \sim 300$ Oe, $k_i \sim 150$ Oe, and $H \approx H_{r1} \approx 1200$ Oe, where H_{r1} is the resonance field for F₁. As a result, keeping only terms not higher than quadratic in H_b/H and k_i/H , we can write

$$\varphi_{02} \approx \varphi_H - \frac{H_b}{H} \sin \varphi_H, \qquad \varphi_{01} \approx \varphi_H.$$
 (11)

After writing the angle variables in the form $\varphi_i = \varphi_{0i} + u_i$, where $|u_i| \ll 1$, the linearized system of equations (7) and (8) can be rewritten as

$$\begin{pmatrix} iH_{\omega} & i\alpha_{1}H_{\omega} + H_{1} & 0 & -k_{1} \\ i\alpha_{1}H_{\omega} + 4\pi M_{1} + H_{1} & -iH_{\omega} & -k_{1} & 0 \\ 0 & -k_{2} & iH_{\omega} & i\alpha_{2}H_{\omega} + H_{2} \\ -k_{2} & 0 & i\alpha_{2}H_{\omega} + 4\pi M_{2} + H_{2} & -iH_{\omega} \end{pmatrix} \times \begin{pmatrix} \varepsilon_{1} \\ u_{1} \\ \varepsilon_{2} \\ u_{2} \end{pmatrix} = \begin{pmatrix} 0 \\ -h \\ 0 \\ -h \end{pmatrix},$$
(12)

where $H_{\omega} = \omega/\gamma$, $H_1 = H + k_1$, $H_2 = H + H_b \cos \varphi_H + k_2$. The coefficients in Eq. (12) were obtained using the expansion $\sqrt{H^2 + 2HH_b} \cos \varphi_H + H_b^2 =$ $H\sqrt{(1 + H_b \cos \varphi_H/H)^2 + (H_b/H)^2 \sin^2 \varphi_H} \approx H +$ $H_b \cos \varphi_H$ under the assumption that $(H_b/H)^2 \ll 1$. For this reason, here and below, the quantitative validity of the calculations is restricted to the terms linear in H_b/H .

Let us recall that the main task of this section consists of determining the angular dependence of the width of the microwave absorption spectrum in the vicinity of the resonance for the free layer F_1 . It is evident that this dependence results from the influence of the pinned layer F_2 on the free layer through the weakly ferromagnetic spacer. To accomplish the task, it is sufficient to analyze the behavior of the determinant of the matrix in Eq. (12) in the vicinity of H_{r1} , and precise analytical determination of $\varepsilon_i(t)$ and $u_i(t)$ is not required.

The absorption intensity I(H) is determined from averaging of the dissipation function over time [4]:

$$I(H) = 2\overline{\mathfrak{R}} \sim \frac{1}{2} \sum_{i=1}^{2} \overline{\alpha_i(\dot{\varepsilon_i}\dot{\varepsilon_i}^* + \dot{u_i}\dot{u_i}^*)}.$$
 (13)

where the asterisk over the angle variables ε_i and u_i means conjugate.

The values of ε_i and u_i are proportional to 1/D, where D = D' + iD'' is the determinant of the matrix of Eq. (12) and D' and D'' are its real and imaginary parts, respectively.

It is easy to show that 1/D can be represented in the form

$$\frac{1}{D} = \frac{A}{\delta' + i\delta''},\tag{14}$$

where

$$A = \frac{H_{\omega}^{2} - H_{2}(H_{2} + 4\pi M_{2}) + i\alpha_{2}H_{\omega}(4\pi M_{2} + 2H_{2})}{\left[H_{\omega}^{2} - H_{2}(H_{2} + 4\pi M_{2})\right]^{2}}, (15)$$

$$\delta' = H_{\omega}^{2} - H(4\pi M_{1} + H) - k_{1}(4\pi M_{1} + 2H) + k_{1}k_{2}K_{0}, (16)$$

$$\delta'' = H_{\omega} \{ \alpha_1 [4\pi M_1 + 2(H + k_1)] - \alpha_1 k_1 k_2 K_1 + \alpha_2 k_1 k_2 K_2 \},$$
(17)

with

$$K_{0} = \frac{4\pi M_{1}}{H} \left(1 + \frac{H}{\pi M_{2}} \right) \left(1 - \frac{M_{1}}{M_{2}} + \frac{H_{b}}{H_{rl}} \cos \varphi \right)^{-1},$$
(18)

$$K_{1} = \frac{1}{H} \left(1 - \frac{M_{1}}{M_{2}} + \frac{H_{b}}{H_{r1}} \cos \varphi \right)^{-1}, \quad (19)$$

$$K_{2} = \frac{4\pi M_{1}}{1} \left[1 + \frac{H}{M_{1}} + \frac{H}{M_{1}} \left(1 + \frac{M_{1}^{2}}{M_{1}} \right) \right]$$

$$\begin{array}{c} H^{2} \left[\begin{array}{c} H^{2} & M_{1} \end{array} + \frac{1}{2} + \frac{1}{2} + \frac{1}{2} \right] \\ \times \left(1 - \frac{M_{1}}{M_{2}} + \frac{H_{b}}{H_{r1}} \cos \varphi \right)^{-2}. \end{array}$$

$$(20)$$

Here the terms quadratic in α_i are neglected.

It follows from Eq. (13) that $I(H) \sim AA^*/(\delta'^2 + \delta''^2)$. Within a narrow field range in the vicinity of the resonance of F₁, sharp changes in the dissipative processes cause changes in δ' and δ'' , while the value of A remains practically unaffected [see Eq. (15)] and can be considered constant.

Resonance conditions for F_1 are obtained when $\delta' = 0$. In this case, the absorption intensity approaches its maximal value:

$$I(H_{\rm r1}) = I_{\rm max} = {\rm const}/\delta^{\prime\prime 2}.$$
 (21)

When magnetic field *H* deviates from H_{r1} , the absorption intensity decreases, and *I* becomes one half of I_{max} for *H* satisfying the following condition:

$$|\delta'|_{H=H_{r1}\pm\Delta_{1}^{\text{hwhm}}} = |\delta''|_{H=H_{r1}}.$$
(22)

After relatively straightforward but cumbersome transformations based on the condition of Eq. (22), one can obtain the angular dependence of the half width at half maximum for the absorption intensity curve:

$$\frac{\Delta_{1}^{\text{hwhm}}}{H_{\omega}} = \alpha_{1} - \alpha_{1} \frac{k_{1}k_{2}}{H_{\text{rl}}^{2}} \frac{\left(1 - \frac{H_{\text{rl}}}{4\pi M_{1}}\right) \left(1 - \frac{M_{1}}{M_{2}}\right)}{\left(1 - \frac{M_{1}}{M_{2}} + \frac{H_{\text{b}}}{H_{\text{rl}}}\cos\varphi\right)^{2}} + \alpha_{2} \frac{k_{1}k_{2}}{H_{\text{rl}}^{2}} \frac{1 + \frac{H_{\text{rl}}}{\pi M_{2}} - \frac{H_{\text{rl}}}{4\pi M_{1}} \left(1 - \frac{M_{1}^{2}}{M_{2}^{2}}\right)}{\left(1 - \frac{M_{1}}{M_{2}} + \frac{H_{\text{b}}}{H_{\text{rl}}}\cos\varphi\right)^{2}}.$$
 (23)

In fabricating our samples, condition $L_1M_1 \approx L_2M_2$ was kept [30,31], which allows reducing the number of independent parameters in the problem by setting $k_1 \approx k_2 \approx k$.

To separate the main factors governing the value of Δ_1^{hwhm} , only terms not higher than quadratic in the small parameter k/H_{r1} were kept in Eq. (23). At the same time, the terms which are proportional to

$$\left(\frac{H_{\rm r1}}{4\pi M_i}\right)^2 \leqslant 0.1, \qquad \left(\frac{H_{\rm b}}{H_{\rm r1}}\right)^2 \leqslant 0.1,$$
$$\frac{H_{\rm b}}{4\pi M_i} = \frac{H_{\rm b}}{H_{\rm r1}} \frac{H_{\rm r1}}{4\pi M_i} \leqslant 0.1, \qquad (24)$$

were neglected (the corresponding values were estimated based on the results of Refs. [3,30,31]).

It is noteworthy that the right-hand side of Eq. (23) does not contain terms linear in k_i : the angular dependence in Δ_1^{hwhm} first appears via a product of the coupling constants, k_1 and k_2 . This kind of Δ_1^{hwhm} vs k_i dependence reflects complex cross-excitation processes between the outer ferromagnetic layers, F₁ and F₂. Due to the non-negligible coupling between the layers, the magnetization of F₂ is "dragged" into oscillations by the resonant precession in F₁. A simultaneous, but much weaker, inverse effect occurs: the magnetization of F₁ experiences an exchange drag from the precession in F₂. It is this kind of cross excitation that affects the relaxation processes in F₁, and depending on the parameters of both ferromagnetic layers coupled via the spacer, this either weakens or enhances the total damping.

Let us consider the situation in the vicinity of the resonance in F_1 . Compared to an isolated F_1 , where all microwave energy would be stored within the layer, the flow of the energy in the coupled F₁-F₂ system divides into two channels: a portion remains stored in F_1 , while the remaining precessional energy leaves outwards and later returns via the above cross-excitation processes. One should keep in mind that there is an additional energy gain in the second channel, which originates from the excitation of F_2 by the external magnetic field. The total energy losses in the system are governed by the processes in both channels. The energy dissipation in the first channel is determined by the intrinsic relaxation mechanisms in F₁, but the energy flow through the second channel depends on the relationship between the processes of energy loss and gain in F₂. If there is no damping in F₂ ($\alpha_2 = 0$) or it is relatively weak ($\alpha_2 < \alpha_1$), the energy losses in the second channel will respectively be zero or small (in comparison with the losses in F₁). Accounting for the additional energy gain due to the excitation of F_2 by the external magnetic field, the total energy losses in the coupled F_1 - F_2 system will be smaller than the losses in an isolated F1, and therefore, the total effective damping parameter of the F₁ layer will be smaller than α_1 . On the contrary, if the energy dissipation in F_2 is relatively strong ($\alpha_2 > \alpha_1$), the energy losses in the second channel will be enhanced, and the total effective damping parameter will be greater than α_1 .

The in-plane anisotropy of Δ_1^{hwhm} originates from the angle dependence of the denominator in the second and third terms of the right-hand-side part of Eq. (23). A close look at the denominator reveals that it represents an approximate form of the difference between the resonance fields of F_1 and F_2 . This reflects the fact that the efficiency of the cross-excitation processes in the coupled F1-F2 system depends not only on the coupling constants k_1 and k_2 but also on the difference between H_{r1} and H_{r2} : the smaller the difference is, the more efficient the processes are. In nanostructures of the spin-valve type, the effect of the exchange bias field \mathbf{H}_{b} is strong inplane unidirectional anisotropy of H_{r2} , with H_{r2} maximally approaching H_{r1} when the external magnetic field is directed opposite to $\mathbf{H}_{b}(\varphi = 180^{\circ})$ [3]. As a result, the cross-excitation processes become most efficient at $\varphi = 180^\circ$, and the above (anti)damping contributions to Δ_1^{hwhm} from F₂ become most pronounced at this angle.

The above effects are illustrated in Fig. 1. Model calculations are carried out with the use of Eq. (23). Figure 1(a) shows the in-plane angle dependencies of the normalized FMR linewidth $\Delta_1^{\text{hwhm}}/H_w$ for different ratios of α_2/α_1 for the case of a moderate interlayer coupling (k = 150 Oe). The dotted line represents the same dependence for an isolated F_1 layer whose damping parameter is α_1 . It is seen that the value of α_2 strongly affects the character of $\Delta_1^{\text{hwhm}}/H_w$ vs φ dependencies. For the case of weak energy dissipation in F₂ $(\alpha_2 = 0)$, the total energy losses in the coupled F₁-F₂ system are smaller than the intrinsic losses in F_1 , so the total effective damping parameter of F_1 is smaller than α_1 . On the contrary, if the energy dissipation in F₂ is relatively strong ($\alpha_2 > \alpha_1$), the total effective damping parameter is greater than α_1 . The increase in α_2 results in both an overall increase in Δ_1^{hwhm} and an enhancement of its in-plane anisotropy. In all cases, the contribution to Δ_1^{hwhm} , induced by the interlayer coupling, is



FIG. 1. In-plane angle dependence of normalized FMR linewidth $\Delta_1^{\text{hwhm}}/H_{\omega}$ for (a) different ratios of α_2/α_1 and (b) different *k*. Dotted lines are for a would-be isolated F₁ layer, whose damping parameter is α_1 .

minimal at $\varphi = 0$ and maximal at 180°. As described above, the difference between H_{r1} and H_{r2} , and hence the cross-excitation processes, achieves opposite extrema at these specific values of the in-plane angle, which is in good agreement with the experimentally observed behavior (see below).

Figure 1(b) illustrates the evolution of $\Delta_1^{\text{hwhm}}/H_w$ vs φ with changes in the coupling constant k. The increase in k leads to both an overall increase in Δ_1^{hwhm} and an enhancement of the in-plane anisotropy of Δ_1^{hwhm} as a result of stronger cross-excitation processes in this stronger exchange-coupling case.

B. Effect of dispersion in local fields

To correctly analyze various contributions to the FMR linewidth, one should take into account the broadening of the linewidth due to fluctuations of the magnetic parameters in the structure, which are always present in the experiment.

In general, FMR in a finite-size ferromagnet is governed by the effective magnetization \mathbf{M}_{eff} , which includes contributions from the spontaneous magnetization \mathbf{M} influenced by the local shape, strain, and crystalline anisotropies [35]. As shown in Ref. [3], the resonance in F_1 and F_2 is governed by the in-plane contributions from the uniaxial, unidirectional, and shape anisotropies, relevant for each of the ferromagnetic layers. The weak uniaxial anisotropy is likely due to the applied field during the multilayer deposition. The unidirectional anisotropy is due to the biasing field \mathbf{H}_b acting on \mathbf{M}_2 and, via the interlayer coupling, on \mathbf{M}_1 [3]. Let us consider the effect of such dispersion in the effective magnetization on the FMR linewidth. Restricting our consideration to the above anisotropy contributions, we can write

$$H_{\rm r} = f(\mathbf{M}, \mathbf{H}_{\rm ua}, \mathbf{H}_{\rm ud}), \qquad (25)$$

(26)

where $H_{\rm r}$ is the magnitude of the resonance field and $H_{\rm ua}$ and $H_{\rm ud}$ are the uniaxial and unidirectional anisotropy fields, respectively. In this case, the inhomogeneous linewidth broadening due to fluctuations in the magnitudes and directions of **M**, $H_{\rm ua}$, and $H_{\rm ud}$ can be written as

 $\Delta^{\text{inhom}} = \Delta_{\mathbf{M}} + \Delta_{\mathbf{H}_{ua}} + \Delta_{\mathbf{H}_{ud}}$

where

$$\Delta_{\mathbf{M}} = \Delta_{M} + \Delta_{\theta} + \Delta_{\varphi}$$
$$= \left| \frac{\partial H_{\mathbf{r}}}{\partial M} \right| \delta M + \left| \frac{\partial H_{\mathbf{r}}}{\partial \theta} \right| \delta \theta + \left| \frac{\partial H_{\mathbf{r}}}{\partial \varphi} \right| \delta \varphi, \qquad (27)$$

$$\Delta_{\mathbf{H}_{ua}} = \Delta_{Hua} + \Delta_{\theta ua} + \Delta_{\varphi ua}$$
$$= \left| \frac{\partial H_{r}}{\partial H_{ua}} \right| \delta H_{ua} + \left| \frac{\partial H_{r}}{\partial \theta_{ua}} \right| \delta \theta_{ua} + \left| \frac{\partial H_{r}}{\partial \varphi_{ua}} \right| \delta \varphi_{ua}, \quad (28)$$

$$\Delta_{\mathbf{H}_{ud}} = \Delta_{Hud} + \Delta_{\theta ud} + \Delta_{\varphi ud}$$
$$|\partial H_{\mathbf{r}}|_{\partial H_{\mathbf{r}}} |\partial H_{\mathbf{r}}|_{\partial \partial H_{\mathbf{r}}} |\partial H_{\mathbf{r}}|_{\partial \partial H_{\mathbf{r}}}$$

$$= \left| \frac{\partial H_{\rm r}}{\partial H_{\rm ud}} \right| \delta H_{\rm ud} + \left| \frac{\partial H_{\rm r}}{\partial \theta_{\rm ud}} \right| \delta \theta_{\rm ud} + \left| \frac{\partial H_{\rm r}}{\partial \varphi_{\rm ud}} \right| \delta \varphi_{\rm ud}.$$
(29)

Here $\Delta_{\mathbf{M}}$, $\Delta_{\mathbf{H}_{ua}}$, and $\Delta_{\mathbf{H}_{ud}}$ are the contributions to the FMR linewidth caused by the dispersion in **M**, **H**_{ua}, and **H**_{ud}, respectively, which in Eqs. (27)–(29) are expressed through the corresponding distributions in magnitudes (δM , δH_{ua} , and δH_{ud}) as well as polar ($\delta \theta$, $\delta \theta_{ua}$, $\delta \theta_{ud}$) and azimuthal ($\delta \varphi$, $\delta \varphi_{ua}$, $\delta \varphi_{ud}$) angles characterizing these vectors.

Based on the analysis of the partial derivatives of H_r , which are contained in Eqs. (27)–(29), it is possible to separate each contribution to Δ^{inhom} by analyzing the out-of-plane and in-plane behaviors of the FMR linewidth [13,23,36]. For example, when out-of-plane measurements are carried out, the azimuthal angle is constant, which means that all contributions containing derivatives in azimuthal angles are constant. For in-plane measurements, on the other hand, all contributions containing derivatives in polar angles are constant. One should also take into account that there are points where some of the partial derivatives found in Eqs. (27)–(29) vanish, making it possible to separate the remaining contributions.

To analyze the various contributions to Δ^{inhom} , we have simulated the out-of-plane and in-plane angle behaviors of the resonance field for a thin ferromagnetic layer, which simultaneously displays in-plane uniaxial and unidirectional anisotropies (the easy axes coincide), and numerically calculated all partial derivatives in Eqs. (27)–(29). Parameters **M**, \mathbf{H}_{ua} , and \mathbf{H}_{ud} were chosen to be close in value to those observed for Py as F₁ and the spacer thickness d = 3 nm [3]. The results of the calculations are shown in Fig. 2.

It is clear from Fig. 2 that the behavior in the out-of-plane geometry is very sensitive to the scatter in θ and M and practically insensitive to the anisotropy parameters. On the other hand, the in-plane behavior provides information on the scatter in both magnitude and orientation of the anisotropy fields (for both uniaxial and unidirectional contributions) and



FIG. 2. (a) Simulated out-of-plane angle dependence of the resonance field H_r for a thin ferromagnetic layer with $M = 520 \text{ emu/cm}^3$, $H_{ua} = 5 \text{ Oe}$, and $H_{ud} = 0 \text{ or } 180 \text{ Oe}$. (b) Calculated contributions to out-of-plane Δ^{inhom} due to fluctuations in magnitude (line 1) and direction (line 2) of spontaneous magnetization and magnitude of in-plane uniaxial (line 3) and unidirectional (line 4) anisotropy fields. Calculations in (a) and (b) were carried out for the x Oz plane, where the Ox axis coincides with $\mathbf{H}_b (\varphi = 0$ for negative θ and $\pm 180^\circ$ for positive θ). (c) Calculated contributions to in-plane Δ^{inhom} due to fluctuations in magnitude (line 1) and direction (line 2) of spontaneous magnetization and magnitude of in-plane uniaxial (line 3) and unidirectional (line 4) anisotropy fields. The distributions in \mathbf{M} , \mathbf{H}_{ua} , and \mathbf{H}_{ud} were chosen to be $\delta M = 5\%$, $\delta \theta = \delta \varphi = 1^\circ$, $\delta H_{ua} = 15\%$, $\delta H_{ud} = 5\%$.

is almost insensitive to the scatter in θ and M. It is worth noting that for the out-of-plane geometry $\Delta^{\text{inhom}}|_{\theta=0} = \Delta^{\text{inhom}}|_{\theta=\pm90^{\circ}}$ in all cases, except for the case where there is a substantial scatter in M.

We point out a peculiar result, important for further analysis of the experimental data, namely, that $\Delta_{Hud}|_{\theta=-90^{\circ}} = \Delta_{Hud}|_{\theta=+90^{\circ}}$, while the resonance field at $\theta = -90^{\circ}$ differs from that at $\theta = +90^{\circ}$, as a result of the in-plane unidirectional anisotropy.

C. Two-magnon scattering

The nature of the dispersion relation of spin waves in ultrathin ferromagnets with in-plane magnetization is such that there can be spin-wave modes of finite wave vector degenerate in frequency with the FMR-exited mode [12,13]. In the ideal case of a nondissipative material, all spin-wave modes are independent, decoupled normal modes of the system, so the FMR mode does not interact with the finite-wave-vector modes of the same frequency. However, if defects of random spatial character are present, they can scatter the zero-wave-vector FMR spin wave into a manifold of degenerate modes [12,13,19–23]. This can be viewed as a dephasing contribution to the linewidth in the language of spin-resonance physics.

The two-magnon mechanism is allowed when the magnetization lies in the film plane or slightly deviates from it and forbidden when the magnetization is perpendicular to the film plane [13,37,38]. Thus, the inequality $\Delta|_{\theta=0} < \Delta|_{\theta=\pm90^{\circ}}$

indicates that two-magnon scattering is potentially relevant for the extrinsic magnetization damping in our case [19].

As a rule, $\Delta|_{\theta=0} = \Delta|_{\theta=\pm90^{\circ}}$ implies that two-magnon scattering plays a negligible role in magnetization relaxation. However, there are specific cases when this damping mechanism displays strong in-plane anisotropy [19,23,39–41]. Since the two-magnon scattering matrix includes elements proportional to the components of the Fourier transform of the spatial distribution of magnetic inhomogeneities, the in-plane anisotropy is expected to be pronounced for the case of oriented extended inhomogeneities, such as rectangular networks of line defects [19,23], one- and two-dimensional rectangular arrays of defects [42], parallel steps [39] or grooves [40], rippled nanostructures [43], etc. One cannot exclude the formation of oriented networks of defects or other inhomogeneous entities in nanostructures deposited under relatively high external magnetic field, such as ours.

D. Spin pumping

In the case where the spin diffusion length L_s of the spacer is smaller than its thickness, the spin current injected by F_1 into the spacer is strongly reduced. For a Curie switch this means that (i) the variation of the spacer thickness should not affect the relaxation of M_1 through the mechanism of spin pumping and (ii) the presence of the pinned layer F_2 should not contribute to the anisotropic damping in F_1 through the same mechanism.

In nonmagnetic metals, L_s is of the order of tens or hundreds of nanometers and in some cases may reach a few micrometers [44]. The addition of impurities or rising temperature reduce L_s . In magnetically ordered materials, especially in alloys, L_s is strongly reduced compared to nonmagnetic metals. For example, at 4.2 K, the spin diffusion length is about 21 nm for Ni, ~8.5 nm for Fe, and ~5.5 nm for Ni₈₄Fe₁₆ [44,45]. At room temperature, L_s for Ni₈₄Fe₁₆ is almost 2 times shorter, about 3 nm [44].

For Cu-Ni alloys, rough estimates of L_s can be made based on the data of Ref. [44]. With the increase in Ni content from 6.9% to 22.7%, the spin diffusion length decreases from ~23 to ~7.5 nm at 4.2 K. It is expected that L_s will be further reduced with the increase in Ni concentration. It is also expected that the temperature rise to 295 K will additionally reduce L_s by 1.5–2 times, likely making it smaller than 3 nm (the minimal spacer thickness in this study) for Ni₅₄Cu₄₆ at room temperature. For this reason, the contribution of the spin-pumping mechanism to the anisotropic damping in F₁ will be neglected for the samples in this study.

IV. EXPERIMENTAL RESULTS AND DISCUSSION

Figures 3(a)-3(c) show the measured resonance field for F₁ versus the out-of-plane angle for multilayers F₁/Ni₅₄Cu₄₆(*d*)/F₂ with *d* = 9, 4.5, and 3 nm. The measurements were carried out in the *xOz* plane, where the *Ox* axis coincides with **H**_b ($\varphi = 0^{\circ}$ for negative θ and $\pm 180^{\circ}$ for positive θ) and the *Oz* axis is the normal to the film plane.

For the sample with d = 9 nm, the behavior of $H_{rl}(\theta)$ is typical of a single permalloy film. The data are quantitatively well described using the Smit-Beljers-Suhl formalism (solid



FIG. 3. Out-of-plane angular dependences of (a)–(c) F_1 resonance fields and (d)–(f) linewidths for $F_1/Ni_{54}Cu_{46}(d)/F_2$ multilayers with different spacer thicknesses. Solid red lines in all panels show simulated angular dependence for d = 9 nm, as described in the text. Insets in (c) present enlarged views of $H_{r1}(\theta)$ near $\theta = \pm 90^{\circ}$.

lines in Fig. 3 are the simulated angular behavior with $M_1^{\text{eff}} = 540 \text{ emu/cm}^3$) [46,47]. A decrease in *d* does not lead to noticeable changes in $H_{r1}(\theta)$ but makes the emergence of unidirectional anisotropy evident: $H_{r1}(+90^\circ)$ becomes greater than $H_{r1}(-90^\circ)$, and the difference between $H_{r1}(+90^\circ)$ and $H_{r1}(-90^\circ)$ grows as *d* decreases [see insets in Fig. 3(c)]. We have previously shown that the unidirectional anisotropy originates from the biasing field \mathbf{H}_b acting on \mathbf{M}_2 , which in turn transmits through the spacer and affects the FMR behavior of \mathbf{M}_1 [3].

The out-of-plane angular dependences of the FMR linewidth for the same multilayers are shown in Figs. 3(d)–3(f). Since the scatter in the magnetic parameters of the decoupled ferromagnetic layer gives different contributions to the linewidth versus angle dependence [see Fig. 2(b)], a detailed analysis of the measured $\Delta_1(\theta)$ curves makes it possible to separate the various local dispersion contributions, as well as the homogeneous contribution.

For the sample with d = 9 nm, the angular variation in the FMR linewidth $\Delta_1(\theta)$ is well described by a homogeneous term within the Smit-Beljers-Suhl formalism [46,47]. This means that the scatter in both the magnitude and orientation of the magnetization in F₁ is negligibly small. The equality $\Delta_1(0^\circ) = \Delta_1(\pm 90^\circ)$ serves as an additional confirmation of the fact that δM_{Py} is negligible [see line 1 in Fig. 2(b)]. The same equality also implies that two-magnon scattering plays a negligible role, at least in the x Oz plane, which includes only two in-plane directions ($\varphi = 0^\circ$ and $\pm 180^\circ$). This, however, does not exclude that two-magnon scattering can contribute to Δ_1 at other in-plane angles (see Sec. III C and discussion below for a more detailed analysis of this mechanism).

For stronger interlayer exchange coupling, the shape of the $\Delta_1(\theta)$ curves shows strong distortions. First, the enhancement of the interlayer interaction leads to an increase in Δ_1 within

a relatively narrow range of angles near $\theta = 0^{\circ}$. Second, the $\Delta_1(\theta)$ dependence transforms from being symmetric to asymmetric: $\Delta_1(+|\theta|)$ becomes greater than $\Delta_1(-|\theta|)$.

It is worth noting that the first effect cannot be caused by the increase of dispersion in the F₁ magnetization as that would substantially increase the linewidth not only for θ near zero but also for other θ values [in particular, for $\theta = \pm 90^{\circ}$; see line 1 in Fig. 2(b)], which is not observed in our experiments. Increased linewidth values within a relatively narrow angle range near $\theta = 0^{\circ}$ were observed in Py/Cu and Py/CuAu multilayers at certain values of the spacer thickness ($d_{\text{Cu}} = 3 \text{ nm or } d_{\text{CuAu}} = 1.4 \text{ nm}$) [48], but no particular explanation was suggested for this effect.

Regarding the second effect, namely, the $\Delta_1(\theta)$ dependence becoming asymmetric, two remarks are in order. (i) This effect is unlikely to result from the scatter in the unidirectional anisotropy fields since, in spite of the *asymmetric* character of $H_{r1}(\theta)$, the H_{ud} dispersion contributes *symmetrically* to the linewidth vs θ dependence [see line 4 in Fig. 2(b)]. (ii) Asymmetry is expected as a result of the enhanced interlayer coupling [see Eq. (23) and Fig. 1]. As detailed in Sec. III A, complementary and more detailed information on this effect can be obtained from the in-plane FMR measurements.

Figure 4(a) shows the in-plane angle dependence of the F₁ resonance field for multilayers F₁/Ni₅₄Cu₄₆(*d*)/F₂ with d = 9, 6, 4.5, and 3 nm. The $H_{r1}(\varphi)$ dependence for the sample with the thickest spacer (d = 9 nm) provides evidence of a weak in-plane uniaxial anisotropy ($H_{ua} \approx 5$ Oe). This contribution is a consequence of the application of external magnetic field during the film deposition, as follows from our tests on Py films grown with and without biasing field. The uniaxial contribution to the anisotropy of the Py layer is found in all of the samples with pinned bottom magnetic layers (deposited in field). As *d* decreases, an additional unidirectional contribution becomes evident and dominates for *d* thinner than 4.5 nm. This contribution is enhanced for stronger interlayer coupling (see above and also Ref. [3]).

The measured $H_{r1}(\varphi)$ were quantitatively analyzed using the formalism developed in Sec. III A and Ref. [3]. Solid lines in Fig. 4(a) are the calculated angular dependence, for which the parameters were either taken from previous work (Λ , M_1^{eff} , M_2^{eff}) [3,31] or obtained from fitting the above $H_{r1}(\varphi)$ data with theoretical m, H_b , and H_{ua} . All these key parameters are presented in Table I. It is important to note that the obtained mand H_b are in good agreement with the results reported earlier [3].

Figure 4(a) shows that stronger interlayer coupling induces unidirectional anisotropy in F₁ as well as lowers the resonance field H_{r1} overall. This behavior can be readily understood within the approach developed in Sec. III A. Following Eq. (14), the resonance conditions for F₁ are fulfilled when δ' equals zero. The analysis of the expression for δ' [see Eq. (16)] shows that, to the first order, H_{r1} is a linear function of k. Since in our case the coupling constant is inversely proportional to the spacer thickness, H_{r1} should be a linear function of 1/d. Figure 4(f) presents the experimentally obtained H_{r1} vs 1/d dependence, with the data points falling quite well on a straight line. This fact, along with the good agreement between the experimental and simulated $H_{r1}(\varphi)$, in addition to the experiment-fitting results reported in Ref. [3], points to



FIG. 4. In-plane angle dependence of (a) the F_1 resonance field and (b)–(e) linewidth for $F_1/Ni_{54}Cu_{46}(d)/F_2$ multilayers with different spacer thicknesses *d*. Solid lines show the simulated behavior for each sample, obtained as described in the text. (f) Resonance field H_{r1} measured at $\varphi = 0^\circ$ versus 1/d. (g) Anisotropic contribution to the FMR linewidth due to the interlayer coupling. The superscript "coupl" means that only this term from the simulated curves of (b)–(e) is taken into account [described by Eq. (23)].

the validity of the theory developed herein for the description of the effect of the interlayer exchange coupling in a Curie switch.

Further, the parameters obtained from the analysis of $H_{r1}(\varphi)$ allowed us to employ the developed theoretical approach to characterize the angular dependences of the FMR linewidth, $\Delta_1(\varphi)$ [Figs. 4(b)–4(e)]. Let us first concentrate on $\Delta_1(\varphi)$ for the sample with d = 9 nm [Fig. 4(b)]. For this case of weak interlayer coupling, the homogeneous contribution to the linewidth does not display any noticeable angular dependence, as shown in Fig. 1. Thus, the clearly visible variation with a 90° periodicity, seen in fact in all samples, is likely to due to local inhomogeneities, namely, from scatter in H_{ua} values [line 3 in Fig. 2(c)]. The solid line in Fig. 4(b) is the simulated $\Delta_1(\varphi)$ dependence, taking into account only two contributions: $2\Delta_1^{hwhm}$ from Eq. (23) and $\Delta_{H_{ua}}$. The good agreement between the experimental and simulated $\Delta_1(\varphi)$ data shows that this effect is due mainly to a scatter in the values of the uniaxial anisotropy field ($\delta H_{ua} \leq 0.2H_{ua}$) in the soft ferromagnetic layer.

As *d* decreases, the shape of $\Delta_1(\varphi)$ undergoes a significant transformation, resulting, in particular, in a much larger difference between $\Delta_1(\pm 180^\circ)$ and $\Delta_1(0^\circ)$ (reaching 23 Oe for d = 3 nm). Such changes cannot be ascribed to any dispersion-type contribution or two-magnon scattering. The use of Eq. (23), on the other hand, makes it possible to describe well this behavior in $\Delta_1(\varphi)$ by taking into account the effect of the interlayer coupling.

In addition to the above-mentioned contributions to the linewidth, scatter in the magnitude of the unidirectional anisotropy $\Delta_{Hud} (\delta H_{ud} < 0.05k)$ was taken into account in the calculations [line 4 in Fig. 2(c)]. This contribution is clearly visible in the data for the sample with d = 3 nm as a plateau in the range of angles $-45^{\circ} \leq \varphi \leq 45^{\circ}$.

Figures 4(b)-4(d) illustrate the good agreement between the measured and modeled $\Delta_1(\varphi)$ for all of the studied samples. In particular, the features in the measured data reflecting the effect of the interlayer coupling on $\Delta_1(\varphi)$ are correctly described by the developed theory [compare, e.g., Figs. 4(g) and 1(b)]. The fitting of the experimental data using Eq. (23) allows us to extract the value of the coupling constant k (given in Table I). The decrease in the spacer thickness from 9 to 4.5 nm strengthens k from 1 to 180 Oe, which in turn enhances the in-plane anisotropy in Δ_1 : the difference between the Δ_1 values along and opposite H_b grows from essentially 0 to 6 Oe (~6% of Δ_1). An even more pronounced effect is observed in the sample with d = 3 nm ($k \approx 690 \text{ Oe}, \Delta_1^* \approx 23 \text{ Oe}$), but we should note that the precision in determining the relevant multilayer properties in this strong-coupling case is not high [see the remark prior to Eq. (24)].

The use of Eq. (23) makes it possible to estimate the damping parameters of F₁ and F₂, α_1 and α_2 , respectively. For the case of d = 6 nm, the obtained α_1 and α_2 values are ~ 0.02 and ~ 0.05 , which are close to those reported in the literature for single Py and CoFe films ($\alpha_1 \sim 0.006/0.02$ and $\alpha_2 \sim 0.05$) [15,25,48]. The increase of the interlayer coupling affects the values of α_1 and α_2 but leaves the ratio α_2/α_1 almost unchanged.

TABLE I. Physical parameters obtained from fitting the experimental data on Curie-switch multilayers: Λ is the exchange length of the spacer, M_1^{eff} and M_2^{eff} are effective magnetization of F₁ and F₂, *m* is effective magnetization of the spacer, H_{ua} is the uniaxial anisotropy field of the F₁ layer, H_b is the biasing field acting on M_2 , *k* is the interlayer coupling constant, and $\Delta_1^* = \Delta_1(\pm 180^\circ) - \Delta_1(0^\circ)$ is the difference in Δ_1 values measured along and opposite to **H**_b.

d (nm)	Λ (nm)	$M_1^{\rm eff}$ (emu/cm ³)	$M_2^{\rm eff}$ (emu/cm ³)	$m (emu/cm^3)$	H _{ua} (Oe)	H _b (Oe)	<i>k</i> (Oe)	Δ_1^* (Oe)
3	11	520	1590	84	5	140	690	23
4.5	11	520	1590	53	5	240	180	6
6	11	520	1590	43	5	270	90	2
9		540			5		1	~ 0.2

A closer look at $\Delta_1(\varphi)$ in Figs. 4(b)-4(d) reveals that there are peaks at $\varphi = \pm 90^{\circ}$ deviating from the predicted behavior (deviating significantly for d = 6 nm). Although a suitably detailed discussion of this finer structure goes beyond the scope of this paper, we would like to offer a suggestion as to the possible mechanism involved. Namely, anisotropic two-magnon scattering discussed in Sec. III C. The source of this type of two-magnon scattering may be related to networks of inhomogeneities with some spatial orientation, formed as a result of the film deposition under the relatively strong external magnetic field needed to induce the exchange pinning by the antiferromagnet. It was shown in Refs. [39,40] that for films with parallel steps or grooves, the two-magnon scattering mechanism makes the FMR linewidth strongly increase in the directions perpendicular to the step edges (grooves). It was also demonstrated in Ref. [49] for the films with periodic stripelike compositional defects that besides intrinsic isotropic Gilbert damping an additional extrinsic anisotropic two-magnon scattering channel with twofold symmetry in the film plane appears. The latter is activated by crystalline defects in the films and is of the same order of magnitude as the fourfold contribution (due to magnetocrystalline anisotropy) and the Gilbert contribution.

Another mechanism that should be kept in mind in this regard is the acoustical and optical collective spin-resonance modes nominally expected in bilayers with intermediate-strength coupling (vanishing for zero and strong coupling) [50]. Such out-of-phase and in-phase mutual oscillations of the two ferromagnetic layers may cause additional dissipation for intermediate k values, a detailed treatment of which requires a separate study.

V. CONCLUSIONS

The FMR linewidth and its anisotropy were studied experimentally and analyzed theoretically for $F_1/f/F_2/AF$ multilayers, where spacer f has a low Curie point compared to the strongly ferromagnetic F_1 and F_2 .

The role of the interlayer exchange coupling in the spinrelaxation processes is investigated by varying the thickness of the spacer. It is shown that stronger interlayer coupling for thinner spacers enhances the microwave energy exchange between the outer ferromagnetic layers, with the magnetization of F_2 exchange dragged by the resonant precession in F_1 . A simultaneous but weaker inverse effect occurs: the magnetization of F_1 can be exchange dragged by the precession in F_2 , which leads to antidamping and narrower FMR linewidths.

Strong interlayer coupling leads to strongly anisotropic magnetization damping, which reaches its maximum for the direction antiparallel to the exchange bias in the system.

An analytical expression [Eq. (23)] was obtained for the angular dependence of the resonance linewidth of the free layer, taking into account the interlayer exchange and the anisotropic contribution from the pinned layer. The presence of a product of the two effective coupling constants (k_1k_2) means that magnetic excitations in the system are interconnected via the interlayer exchange, which allows for collective excitation modes. Of note is that this key expression is universal for describing the resonance linewidth in multilayer structures with interlayer exchange (of various microscopic natures).

By theoretically fitting the measured FMR data, the different contributions to the magnetic relaxation in the system were separated and discussed. Key physical parameters, such as the interlayer coupling constant and the in-plane anisotropy of the FMR linewidth, were quantified.

It was shown that in addition to the FMR relaxation effects related to the interlayer coupling, dispersion of the magnetic anisotropy fields in all of the layers can contribute to the FMR linewidth of F_1 . Quantitative data for the dispersion parameters of the multilayer were obtained.

These results should be useful for designing high-speed nanodevices based on spin-thermionic control.

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- Nanomagnetism and Spintronics, edited by T. Shinjo (Elsevier, Oxford, 2009), p. 346.
- [2] A. Zyubin, A. Orlova, A. Astashonok, G. Kupriyanova, and V. Nevolin, J. Phys. Conf. Ser. 324, 012013 (2011).
- [3] A. F. Kravets, A. I. Tovstolytkin, Y. I. Dzhezherya, D. M. Polishchuk, I. M. Kozak, and V. Korenivski, J. Phys. Condens. Matter 27, 446003 (2015).
- [4] L. D. Landau and E. M. Lifshitz, in *Collected Papers of L.D. Landau*, edited by D. ter Haar (Pergamon Press, New York, 1965), 1st ed., Chap. 18, pp. 101–114.
- [5] C. Serpico, I. D. Mayergoyz, and G. Bertotti, J. Appl. Phys. 93, 6909 (2003).
- [6] T. L. Gilbert, IEEE Trans. Magn. 40, 3443 (2004).
- [7] J. A. Katine, F. J. Albert, R. A. Buhrman, E. B. Myers, and D. C. Ralph, Phys. Rev. Lett. 84, 3149 (2000).

- [8] S. Petit, C. Baraduc, C. Thirion, U. Ebels, Y. Liu, M. Li, P. Wang, and B. Dieny, Phys. Rev. Lett. 98, 077203 (2007).
- [9] A. Brataas, A. D. Kent, and H. Ohno, Nat. Mater. 11, 372 (2012).
- [10] H. Suhl, IEEE Trans. Magn. **34**, 1834 (1998).
- [11] V. Kamberský, Can. J. Phys. 48, 2906 (1970).
- [12] M. Sparks, *Ferromagnetic-Relaxation Theory* (McGraw-Hill, New York, 1964).
- [13] K. Zakeri, J. Lindner, I. Barsukov, R. Meckenstock, M. Farle, U. von Hörsten, H. Wende, W. Keune, J. Rocker, S. S. Kalarickal, K. Lenz, W. Kuch, K. Baberschke, and Z. Frait, Phys. Rev. B 76, 104416 (2007).
- [14] S. Mizukami, Y. Ando, and T. Miyazaki, Phys. Rev. B 66, 104413 (2002).
- [15] Y. Tserkovnyak, A. Brataas, and G. E. W. Bauer, Phys. Rev. Lett. 88, 117601 (2002).

- [16] M. J. Hurben and C. E. Patton, J. Appl. Phys. 83, 4344 (1998).
- [17] A. V. Nazarov, D. Ménard, J. J. Green, C. E. Patton, G. M. Argentina, and H. J. Van Hook, J. Appl. Phys. 94, 7227 (2003).
- [18] N. Mo, Y.-Y. Song, and C. E. Patton, J. Appl. Phys. 97, 093901 (2005).
- [19] J. Lindner, K. Lenz, E. Kosubek, K. Baberschke, D. Spoddig, R. Meckenstock, J. Pelzl, Z. Frait, and D. L. Mills, Phys. Rev. B 68, 060102 (2003).
- [20] K. Lenz, H. Wende, W. Kuch, K. Baberschke, K. Nagy, and A. Jánossy, Phys. Rev. B 73, 144424 (2006).
- [21] R. D. McMichael, D. J. Twisselmann, and A. Kunz, Phys. Rev. Lett. 90, 227601 (2003).
- [22] A. Butera, J. Gómez, J. L. Weston, and J. A. Barnard, J. Appl. Phys. 98, 033901 (2005).
- [23] G. Woltersdorf and B. Heinrich, Phys. Rev. B 69, 184417 (2004).
- [24] I. K. Yanson, Y. G. Naidyuk, D. L. Bashlakov, V. V. Fisun, O. P. Balkashin, V. Korenivski, A. Konovalenko, and R. I. Shekhter, Phys. Rev. Lett. 95, 186602 (2005).
- [25] A. A. Timopheev, Y. G. Pogorelov, S. Cardoso, P. P. Freitas, G. N. Kakazei, and N. A. Sobolev, Phys. Rev. B 89, 144410 (2014).
- [26] S. Andersson and V. Korenivski, IEEE Trans. Magn. 46, 2140 (2010).
- [27] S. Andersson and V. Korenivski, J. Appl. Phys. 107, 09D711 (2010).
- [28] A. M. Kadigrobov, S. Andersson, D. Radić, R. I. Shekhter, M. Jonson, and V. Korenivski, J. Appl. Phys. 107, 123706 (2010).
- [29] A. M. Kadigrobov, S. Andersson, H. C. Park, D. Radić, R. I. Shekhter, M. Jonson, and V. Korenivski, J. Appl. Phys. 111, 044315 (2012).
- [30] A. F. Kravets, A. N. Timoshevskii, B. Z. Yanchitsky, M. A. Bergmann, J. Buhler, S. Andersson, and V. Korenivski, Phys. Rev. B 86, 214413 (2012).
- [31] A. F. Kravets, Y. I. Dzhezherya, A. I. Tovstolytkin, I. M. Kozak, A. Gryshchuk, Y. O. Savina, V. A. Pashchenko, S. L. Gnatchenko, B. Koop, and V. Korenivski, Phys. Rev. B 90, 104427 (2014).

- [32] A. Aharoni, *Introduction to the Theory of Ferromagnetism* (Oxford University Press, Oxford, 1996).
- [33] J. Nogués, J. J. Sort, V. Langlais, V. Skumryev, S. Suriñach, J. Muñoz, and M. Baró, Phys. Rep. 422, 65 (2005).
- [34] G. S. Abo, Y.-K. Hong, J. Park, J. Lee, W. Lee, and B.-C. Choi, IEEE Trans. Magn. 49, 4937 (2013).
- [35] A. G. Gurevich and G. A. Melkov, *Magnetization Oscillations and Waves* (CRC Press, Boca Raton, FL, 1996).
- [36] S. Mizukami, Y. Ando, and T. Miyazaki, Jpn. J. Appl. Phys. 40, 580 (2001).
- [37] R. P. Erickson and D. L. Mills, Phys. Rev. B 46, 861 (1992).
- [38] P. Landeros, R. E. Arias, and D. L. Mills, Phys. Rev. B 77, 214405 (2008).
- [39] R. Arias and D. L. Mills, J. Appl. Phys. 87, 5455 (2000).
- [40] R. D. McMichael, D. J. Twisselmann, J. E. Bonevich, A. P. Chen, W. F. Egelhoff, Jr., and S. E. Russek, J. Appl. Phys. 91, 8647 (2002).
- [41] D. J. Twisselmann and R. D. McMichael, J. Appl. Phys. 93, 6903 (2003).
- [42] R. A. Gallardo, A. Banholzer, K. Wagner, M. Körner, K. Lenz, M. Farle, J. Lindner, J. Fassbender, and P. Landeros, New J. Phys. 16, 023015 (2014).
- [43] M. Körner, K. Lenz, R. A. Gallardo, M. Fritzsche, A. Mücklich, S. Facsko, J. Lindner, P. Landeros, and J. Fassbender, Phys. Rev. B 88, 054405 (2013).
- [44] J. Bass and W. P. Pratt, Jr., J. Phys. Condens. Matter 19, 183201 (2007).
- [45] C. E. Moreau, I. C. Moraru, N. O. Birge, and W. P. Pratt, Jr., Appl. Phys. Lett. 90, 012101 (2007).
- [46] H. Suhl, Phys. Rev. 97, 555 (1955).
- [47] J. Smit and H. G. Beljers, Philips Res. Rep. 10, 113 (1955).
- [48] J. Dubowik and F. Stobiecki, J. Magn. Magn. Mater. 242–245, 538 (2002).
- [49] I. Barsukov, P. Landeros, R. Meckenstock, J. Lindner, D. Spoddig, Z.-A. Li, B. Krumme, H. Wende, D. L. Mills, and M. Farle, Phys. Rev. B 85, 014420 (2012).
- [50] A. Konovalenko, E. Lindgren, S. S. Cherepov, V. Korenivski, and D. C. Worledge, Phys. Rev. B 80, 144425 (2009).